Vertically-oriented MoS$_2$ nanosheets for nonlinear optical devices†

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Transition metal dichalcogenides such as MoS$_2$ represent promising candidates for building blocks of ultra-thin nanophotonic devices. For such applications, vertically-oriented MoS$_2$ (v-MoS$_2$) nanosheets could be advantageous as compared to conventional horizontal MoS$_2$ (h-MoS$_2$) given that their inherent broken symmetry would favor an enhanced nonlinear response. However, the current lack of a controllable and reproducible fabrication strategy for v-MoS$_2$ limits the exploration of this potential. Here we present a systematic study of the growth of v-MoS$_2$ nanosheets based on the sulfurization of a pre-deposited Mo–metal seed layer. We demonstrate that the sulfurization process at high temperatures is driven by the diffusion of sulfur from the vapor–solid interface to the Mo seed layer. Furthermore, we verify an enhanced nonlinear response in the resulting v-MoS$_2$ nanostructures as compared to their horizontal counterparts. Our results represent a stepping stone towards the fabrication of low-dimensional TMD-based nanostructures for versatile nonlinear nanophotonic devices.

Introduction

Two-dimensional (2D) materials such as transition metal dichalcogenides (TMDs) have been extensively exploited for a wide range of applications including optoelectronics devices$^{1,2}$ and catalysis$^3$ among others. Specifically, these materials exhibit numerous remarkable electronic and optical properties thanks to their broken inversion symmetry.$^{1-6}$ Significant attention has been recently devoted to their nonlinear optical response,$^{7-9}$ which makes TMDs ideal building blocks for ultra-thin$^{10}$ nonlinear photonic devices.$^{11}$

Such nonlinear optical effects have been demonstrated in horizontal MoS$_2$ (h-MoS$_2$) monolayers, displaying a marked dependence on the specific crystalline symmetry and orientation.$^{12}$ For instance, a nonlinear optical response has been reported at the atomic edges of h-MoS$_2$ crystals, where translation symmetry is broken.$^{13}$ These findings suggest that vertically-oriented MoS$_2$ (v-MoS$_2$) nanosheets, a configuration that maximizes the number of exposed edge sites, could represent a promising platform to enhance the second-order nonlinear response and realize a novel candidate for the building blocks of high efficiency nanophotonic devices.

On the one hand, significant progress has been achieved in the understanding of the growth dynamics of horizontal MoS$_2$. Different fabrication methods have been employed, such as chemical vapor deposition (CVD) techniques,$^{14,15}$ the direct sulfurization of a pre-deposited molybdenum (Mo) seed layer,$^{16,17}$ the solvothermal/hydrothermal approach,$^{18}$ and by using a vapor phase reaction with MoO$_3$.$^{19,20}$

On the other hand, the growth mechanism of its vertical counterpart, v-MoS$_2$, remains still poorly understood. Several attempts at explaining the growth of vertically-oriented MoS$_2$ nanostructures have been put forward. For instance, in the context of growth strategies based on the sulfurization of a pre-existing Mo–metal layer,$^{21}$ it has been shown that a low reaction temperature of 350 °C results into v-MoS$_2$ with the kinetically-controlled growth being diffusion limited. Furthermore, it has been reported that the orientation of the resulting MoS$_2$ layers with respect to the substrate is sensitive to the thickness of the Mo–metal layer.$^{22}$ Specifically, thicker and more uniform Mo–metal seed layers lead to a higher fraction of v-MoS$_2$ layers. Additionally, theoretical models have been also constructed aiming to describe the synthesis of vertically-oriented MoS$_2$ based on the solid-vapor reaction,$^{21-24}$ though most of these predictions remain to be verified.

Given this state of affairs, achieving further progress towards a controllable and reproducible fabrication strategy for v-MoS$_2$ requires detailed studies of the associated growth mechanisms. Here we present a systematic investigation of the
growth mechanism of vertical MoS$_2$ nanosheets based on the
growth of a pre-deposited Mo–metal seed layer. Thanks
to an extensive structural cross-section characterization by
means of transmission electron microscopy (TEM), we demon-
strate that the sulfurization mechanism for temperatures
between 600 and 700 °C proceeds via diffusion. These findings
imply that during the sulfur reaction the growth propagates
from the vapor–solid interface inwards into the Mo seed layer.
In addition, we investigate the prospects of the resulting v-MoS$_2$
nanostuctures for nonlinear optical applications. We verify an enhanced nonlinear response as compared to their
h-MoS$_2$ counterparts, confirmed by the observation of second-
harmonic generation and sum-frequency generation.

Our results provide a stepping stone towards the large-scale
fabrication of high-quality v-MoS$_2$ nanosheets, and represent a
crucial step in a program aimed at designing and fabricating
low-dimensional nanostructures for the development of
efficient and versatile nonlinear optical devices based on 2D
materials.

Results and discussion

A two-step process was used for synthesizing the vertically-
oriented MoS$_2$ nanosheets by means of the sulfurization of a
pre-deposited Mo–metal layer. A thick Mo seed layer of 700 nm
was chosen in order to be able to ascertain the dependence on
the reaction time and the sulfurization depth. The sulfuriza-
tion process was carried out inside a three-zone hot-wall hori-
zontal tube. Before and during the sulfurization, an Argon gas
flow was used to prevent any possible oxidation as well as a
carrier to transport the Sulphur vapor phase to the substrate.
Further details about the growth process are described in the
ESI.$^\dagger$

The orientation of the resulting MoS$_2$ nanosheets was inves-
tigated as a function of the reaction temperature. For these
studies, we considered several growth temperatures in the
range between 500 °C and 700 °C. We now highlight the
results obtained for the two limiting cases corresponding to
temperatures of 500 °C and 700 °C.

Fig. 1a and b display top-view scanning electron microscopy
(SEM) images of the sulfurized Mo–metal layer at 500 and
700 °C respectively. One observes marked differ-
ences in the morphology between the results obtained in the two
growths. While the vertical nature of the MoS$_2$ nanosheets grown at a
temperature of 500 °C is unambiguous from the SEM image
(Fig. 1a), the same inspection is less conclusive for the sample
grown at 700 °C, whose surface exhibits a granular-like aspect
(Fig. 1b).

Fig. 1c and d depict Raman spectroscopy measurements
taken in the samples grown at 500 and 700 °C, respectively.
These Raman spectra are dominated by the in-plane $E_{12g}$ and
the out-of-plane $A_{1g}$ Raman modes. The appearance and posi-
tion of these peaks is consistent with a trigonal prismatic
(2H-MoS$_2$) crystal phase, further confirming the successful
MoS$_2$ growth.$^{25}$

Interestingly, we find that for the sample grown at 500
(700) °C the ratio of intensities between the $A_{1g}$ and $E_{12g}$ peaks
increases by a factor 2 (3) as compared to regular MoS$_2$ flakes,
where the two peaks exhibit comparable intensities.$^{22}$ Given

![Fig. 1](image_url) (a) and (b) Top-view SEM images of the surface of the samples sulfurized at 500 and 700 °C, respectively. (c) and (d) The associated Raman spectra, where the two main Raman modes ($A_{1g}$ and $E_{12g}$) are visible along with the smaller $E_{1g}$ mode. The similarities between the two spectra suggest the vertical orientation of the MoS$_2$ nanosheets in the samples grown at both temperatures.
that the A_{1g} and E^{1}_{2g} Raman peaks are associated respectively with the out-of-plane and in-plane vibration modes; these results suggest that our specimens exhibit the presence of v-MoS_{2} nanosheets in the samples grown at both temperatures, therefore indicating a higher density of exposed edges.

Furthermore, in Fig. 1c (1d) a third peak located at 287 (283) cm\(^{-1}\) and associated to the E_{1g} Raman mode is also observed. This mode is forbidden in backscattering experiments,\(^{26}\) which implies that it should not be observed when the incident laser beam is perpendicular to the basal plane, as happens for horizontal MoS_{2}. The presence of the E_{1g} mode thus indicates that the laser beam is no longer perpendicular to the incident (basal) plane, providing a further confirmation of the presence of vertically-oriented (with respect to the substrate) MoS_{2} nanosheets in both samples.

To investigate the orientation of the grown MoS_{2}, we further complement this surface analysis with a cross-section study performed by focus ion beam (FIB) followed by SEM inspection. For the sample grown at 500 °C (Fig. 2a), the thickness of the original Mo seed layer (700 nm) remains mostly unaffected after sulfurization. However, for the sample grown at 700 °C (Fig. 2b), the Mo seed layer is close to being fully sulfurized. From the cross-section SEM image, one observes that the original thickness of the Mo-metal layer has been reduced down to a length of 200 nm, with the rest of the Mo layer sulfurized into MoS_{2}. In this specific case, the final sulfurized layer has a length of 1.95 µm, representing a factor of around three increase as compared to the thickness of the initial Mo layer. From these experimental results, one can therefore distinguish two distinctive dynamics for the growth of the v-MoS_{2} nanosheets. On the one hand, at 500 °C, the sulfur only reacts on the immediate Mo seed layer surface, leading to vertically-standing MoS_{2}, as can be observed in the top-view SEM image in Fig. 1a. On the other hand, at 700 °C, the sulfur diffuses through the Mo seed layer by consuming it and forming v-MoS_{2} layers.

To investigate the crystalline quality of the vertical MoS_{2} grown at 700 °C, we have produced a cross-section sample using FIB and then analyzed it by means of transmission electron microscopy (TEM). The three different contrasts observed in Fig. 3a reveal the sequence MoS_{2}, Mo-metal, and Silicon. The high-resolution TEM (HRTEM) measurements performed at the MoS_{2}/Mo interface (Fig. 3b) indicate that the MoS_{2} grows vertically with respect to the Mo seed layer. The distance between two neighboring MoS_{2} layers was measured to be about 0.65 nm (Fig. 3c), consistent with previous results in the literature.\(^{27}\) Energy dispersive X-ray spectroscopy (EDX) measurements along the length of the whole cross-section (Fig. 3d) provide clear evidence of the sulfur diffusion into the Mo seed layer that results into the growth of the vertically-oriented MoS_{2} nanosheets.

Growth mechanism of vertically-oriented MoS_{2} nanosheets at 700 °C

In order to further elucidate the sulfurization mechanism of the v-MoS_{2} at 700 °C, we have sulfurized for different times sample containing each 700 nm of Mo seed layer. Subsequently, we prepared with FIB cross-sections lamellas for TEM and EDX inspection that allowed us to determine the thicknesses of the MoS_{2} layer and of the consumed Mo. We have only considered reactions times equal to and larger than 15 min, in a way that the Mo seed layer will be always completely sulfurized, see Fig. S5. In Fig. 4a we display the value of the consumed Mo seed layer as a function of the reaction time. These measurements are fitted to a model of the form z = K(t − t_0)^n, with z and t are the thickness of the consumed Mo seed layer and the reaction time respectively. The best-fit value for the growth exponent n is found to be 0.48. The fact that n is very close to 1/2 is consistent with a sulfurization process dominated by the diffusion mechanism.

Since the growth exponent is essentially 0.5, we can use the relation z_{diff} = 2\sqrt{Dt} to extract from the data the diffusion coefficient of sulfur within the Mo seed layer. The best-fit value for D is calculated to be 20.7 nm\(^2\) s\(^{-1}\), similar to the diffusion coefficients measured for sulfur in other metals.\(^{28}\)
Our findings therefore confirm that the reaction is driven by the diffusion of the sulfur and that the consumption of sulfur takes place predominantly at the boundary between the Mo seed layer and the grown v-MoS\(_2\) layers. These results are consistent with theoretical models of the diffusion-reaction growth proposed for the synthesis of vertically-oriented MoS\(_2\).\(^{29}\)

From the HR-TEM cross-section lamella analysis (Fig. S4†) we also found an orientation-disordered region extending from the surface to the first 20 nanometers, where both vertical and horizontal MoS\(_2\) nanosheets are present. The reaction mechanism in this initial region appears to be self-limited,\(^{29}\) but then from this point onwards the growth front results into v-MoS\(_2\) being dominated by the diffusion kinetics of sulfur, as discussed above.

The influence of the temperature on the rate of the consumed Mo seed layer was also examined in the range between 600 and 700 °C. The lower range of this interval corresponds to the minimum temperature required to initiate the diffusion of the sulfur within the Mo seed layer.\(^{21}\) A fixed reaction time of 30 min was adopted in these experiments. Fig. 4b highlights the effect of the rate of the MoS\(_2\) thickness growth as a function of the reaction temperature. The experimental Arrhenius plot can be fitted very well by a straight line to determine the activation energy required to sulfurize the Mo seed layer.\(^{49}\)
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Nonlinear optical effects in vertical-oriented MoS2 nanosheets

As mentioned above, TMD materials have generated ample attention because of their nonlinear optical response.7 In particular, second and third-order nonlinear optical processes have recently been demonstrated in few-layer MoS2 flakes. Second-harmonic (SHG) and sum-frequency generation (SFG) have been shown to be more efficiently generated in thin MoS2 flakes with a few atomic layers.30,31 The intensity of both processes exponentially increases when decreasing the number of layers, thus revealing MoS2 monolayers to be the most efficient thickness in order to generate second-order processes. Moreover, due to inversion symmetry breaking, only odd-layered MoS2 flakes present second-order processes, (i.e. MoS2 layered semiconductors have vanishing $\chi^{(2)}$ due to symmetry when the number of layers is even). In contrast, third-order processes, such as four-wave mixing (FWM), gradually increase their intensity with increasing number of layers (reaching saturation for a certain thickness) irrespective of their parity.

It is also worth noting that the study of nondegenerate optical processes in MoS2 flakes using multi-color multi-phonon spectroscopy is very limited in the literature.7,12

Here we use multiphoton spectroscopy to explore the nonlinear optical response of the synthesized vertical MoS2 nanosheets reported in this work, and compare the results with those of their h-MoS2 counterparts. Fig. 5a depicts the spectra of the nonlinear emission when excited with a laser pulse at 776 nm (blue line) and with two synchronized laser pulses at 776 nm and 1210 nm (red line). The labels indicate the nonlinear mechanisms that originate the emission at each spectral peak. The spectra in Fig. 5a illustrate all the above-mentioned processes. In order to benchmark the response of the v-MoS2 nanosheets in Fig. 5a, we also measured the nonlinear emission of the horizontally-oriented case. Fig. 5b shows the spectra collected upon laser illumination with a single 776 nm beam (blue line) and both beams at 776 nm and 1210 nm (red line). Although both MoS2 geometries exhibit the same emission peaks (except SHG$_3$), it is clear that vertically-oriented MoS2 nanosheets favor second-order processes (i.e. SFG in Fig. 5a) over third-order processes (i.e. THG and FWM in Fig. 5a). In contrast, the horizontal configuration shows the opposite trend where third-order processes dominate and second-order processes are three orders of magnitude smaller due to inversion symmetry, in agreement with previous results in the literature.12,32

By using the intensity of the spectral peaks for SFG and SHG along with the power of the excitation beams, one can estimate the relative ratio of the nonlinear susceptibility.7,13

The relevant formulae related to second harmonic generation and sum frequency generation are provided in the ESI-G.† The second-order susceptibility ratios between the vertical and horizontal geometries extracted from SHG and SFG turn out to be $\chi^{(2)}_{V}/\chi^{(2)}_{H} \approx 22.9 \pm 1.5$ and $\chi^{(2)}_{V}/\chi^{(2)}_{H} \approx 24.7 \pm 1.0$, respectively. These results indicate that vertically-oriented MoS2 nanosheets significantly favor second-order nonlinear processes as compared to their horizontal counterparts. As mentioned above, this enhancement can be traced back to the effects of inversion symmetry breaking at the exposed edges of the nanosheets.

Conclusions

In this work we have reported the controllable and reproducible fabrication of vertically-oriented MoS2 nanosheets. We have demonstrated that the phase transformation from Mo seed layers to vertically-oriented 2H-MoS2 nanosheets can be achieved by means of reacting the pre-deposited Mo–metal layer with sulfur at relatively high temperatures, in the range between 600 and 700 °C. Following a systematic characterization analysis of these v-MoS2 nanosheets using TEM and EDX, we have established that in this range of temperatures the sulfurization mechanism proceeds via diffusion.

Furthermore, we have investigated the nonlinear optical response of the resulting v-MoS2 nanostructures, including second-harmonic generation, and found an enhanced second-order nonlinear response as compared to the h-MoS2 case. The latter property could be explained by the effects of inversion symmetry breaking at the exposed edges of the nanosheets.
Our findings therefore represent a stepping stone towards the fabrication of low-dimensional TMD-based nanostuctures for versatile nonlinear nanophotonic devices. This above-mentioned nonlinear property combined with the versatility of the synthesis method have the potential to create flexible, large area, nonlinear photonic devices based on a wide array of layered materials.

Methods

Sample preparation

A two-step process was used for synthesizing the vertically-oriented MoS$_2$ nanosheets. First, a 700 nm-thick Mo seed layer was pre-deposited on a Si/SiO$_2$ wafer using magnetron sputtering. The sulfurization was carried out in a gradient tube furnace from Carbolite Gero. Note that Argon gas was used as a carrier gas. The Ar flow was set up 150 sccm for all the syntheses (see Fig. S2†). This Mo seed layer was placed in the middle zone and gradually heated up to the reaction temperature. Once the sample reached the reaction temperature, 400 mg of sulfur was heated to 220 °C (see Fig. S1-S3†). The sulfur was placed upstream from the sample. Further details on the synthesis can be found in the ESI.

Characterization techniques

Transmission electron microscopy (TEM) measurements. TEM and energy-dispersive X-ray spectroscopy were carried out in a Titan Cube microscope operated at 300 kV. Its spatial resolution at Scherzer defocus conditions is 0.08 nm in the High-resolution TEM mode, whilst the resolution is around 0.19 nm in the High-Angle Annular Dark-Field Scanning Transmission Electron Microscopy (HAADF-STEM). Cross-section TEM lamellas were fabricated using a FEI Helios G4 CXT™ dual beam system.

Raman spectroscopy. Raman spectroscopy was performed using a Renishaw InVia Reflex™ confocal Raman microscope. The wavelength of the exiting laser was 514 nm, and a 1800 l/mm grating was used resulting in a spectral resolution of around 1 cm$^{-1}$.

Optical measurements. For the nonlinear optical measurements, the specimen was prepared by means of the ultramicrotomy technique. See ESI-E† for more details. The specimen was illuminated with two synchronized laser pulses at $\lambda_1 = 776$ nm and $\lambda_2 = 1210$ nm that were temporally and spatially overlapped. The laser pulses were generated by a femtosecond laser oscillator (Tsunami, Spectra-Physics) and an optical parametric oscillator (OPAL, Spectra-Physics). Both laser beams were focused onto the sample using a microscope objective (Olympus UP-LSAPO 40×/0.95), which also collects the emitted light originated through the nonlinear laser+MoS$_2$-nanosheets interaction. The collected light was filtered and imaged onto the slit of a spectrometer (PI, Spectra Pro 2300I). In these measurements the second-order susceptibility $\chi^{(2)}$ gives rise to the second-harmonic generation (SHG) and the sum-frequency generation (SFG) at $2\omega_1, 2\omega_2$ and $\omega_1 + \omega_2$. The third-order susceptibility $\chi^{(3)}$ mediates the generation of nonlinear polarization $P^{(3)}$, resulting in third-harmonic generation (THG) and four-wave mixing (FWM) at $3\omega_2$ and $2\omega_1 - \omega_2$, respectively.

Conflicts of interest

There are no conflicts to declare.

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References

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